

FIG. 1
PRIOR ART

TOFE20" 0592T650

Title: METHOD AND APPARATUS FOR USING AN EXCIMER LASER TO PATTERN
ELETRODEPOSITED PHOTORESIST

Inventor(s): Laurie S. MITTELSTAEDT

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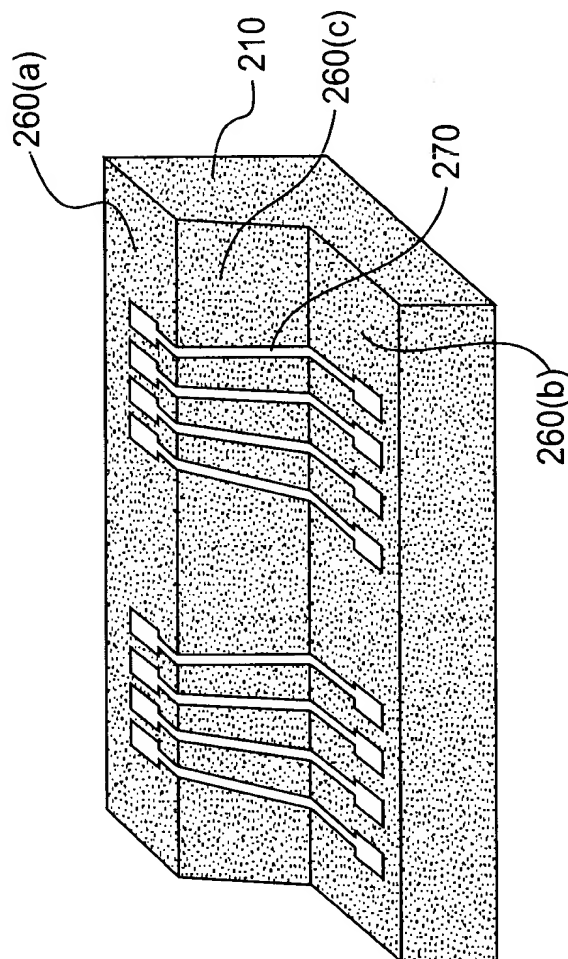


FIG. 2

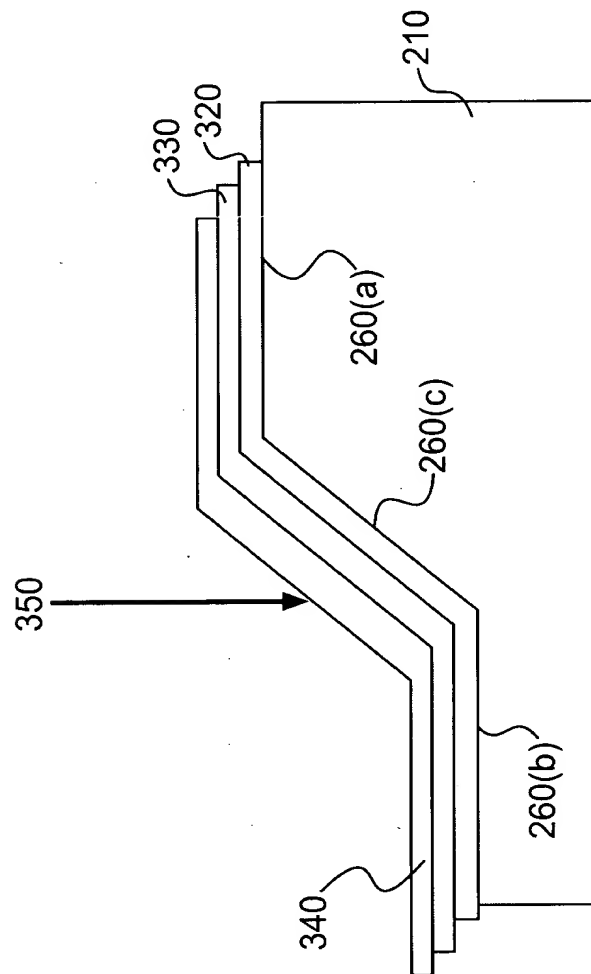


FIG. 3

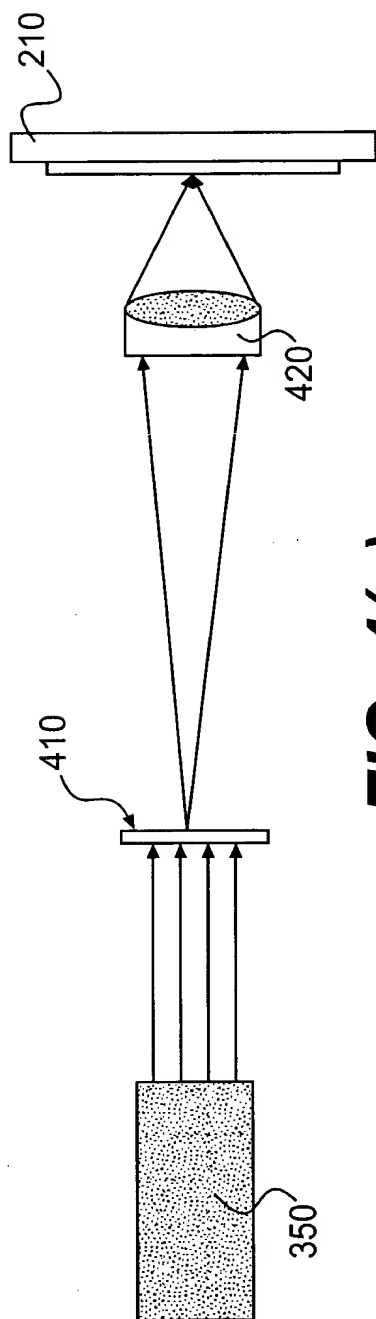


FIG. 4(a)

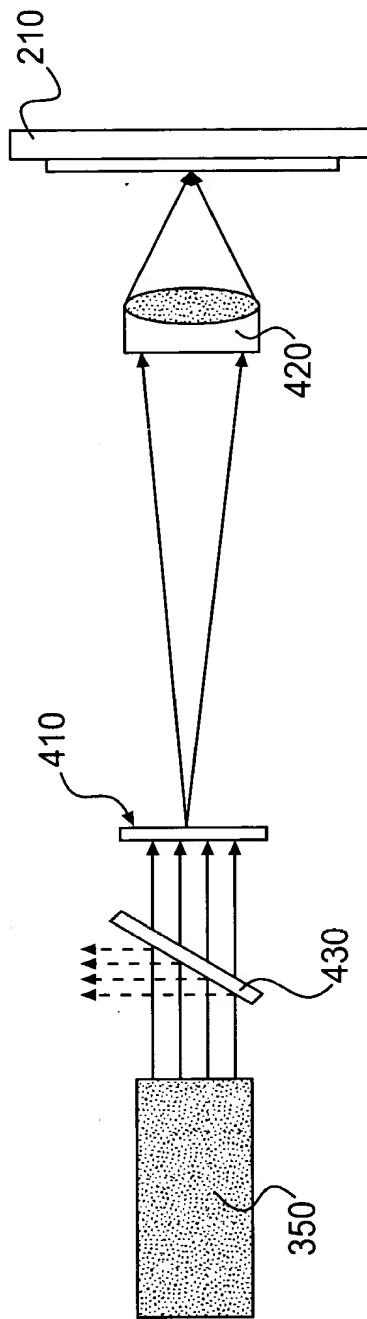


FIG. 4(b)

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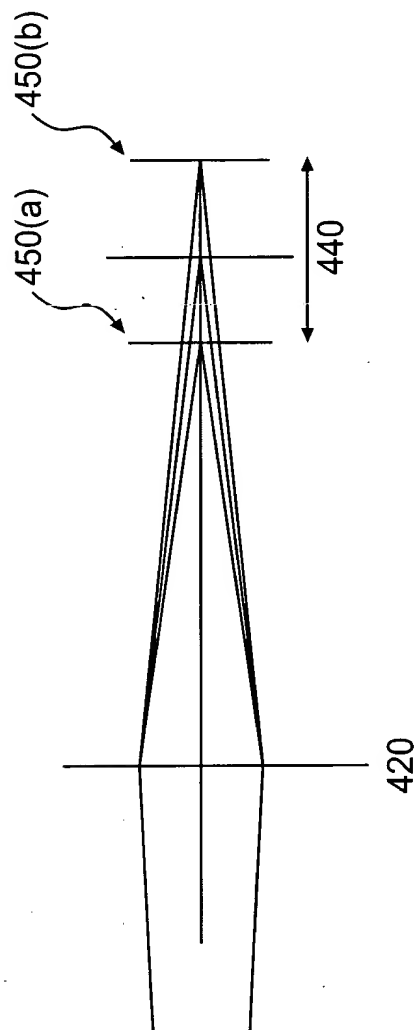


FIG. 4(c)

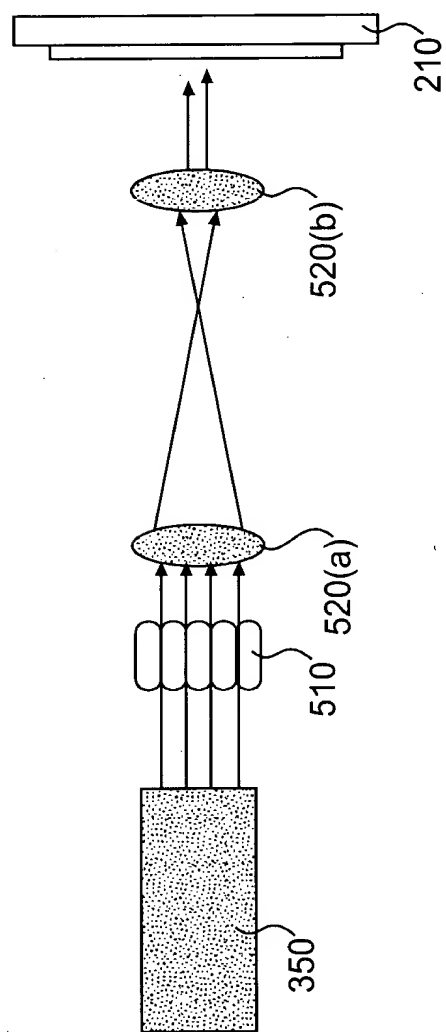


FIG. 5

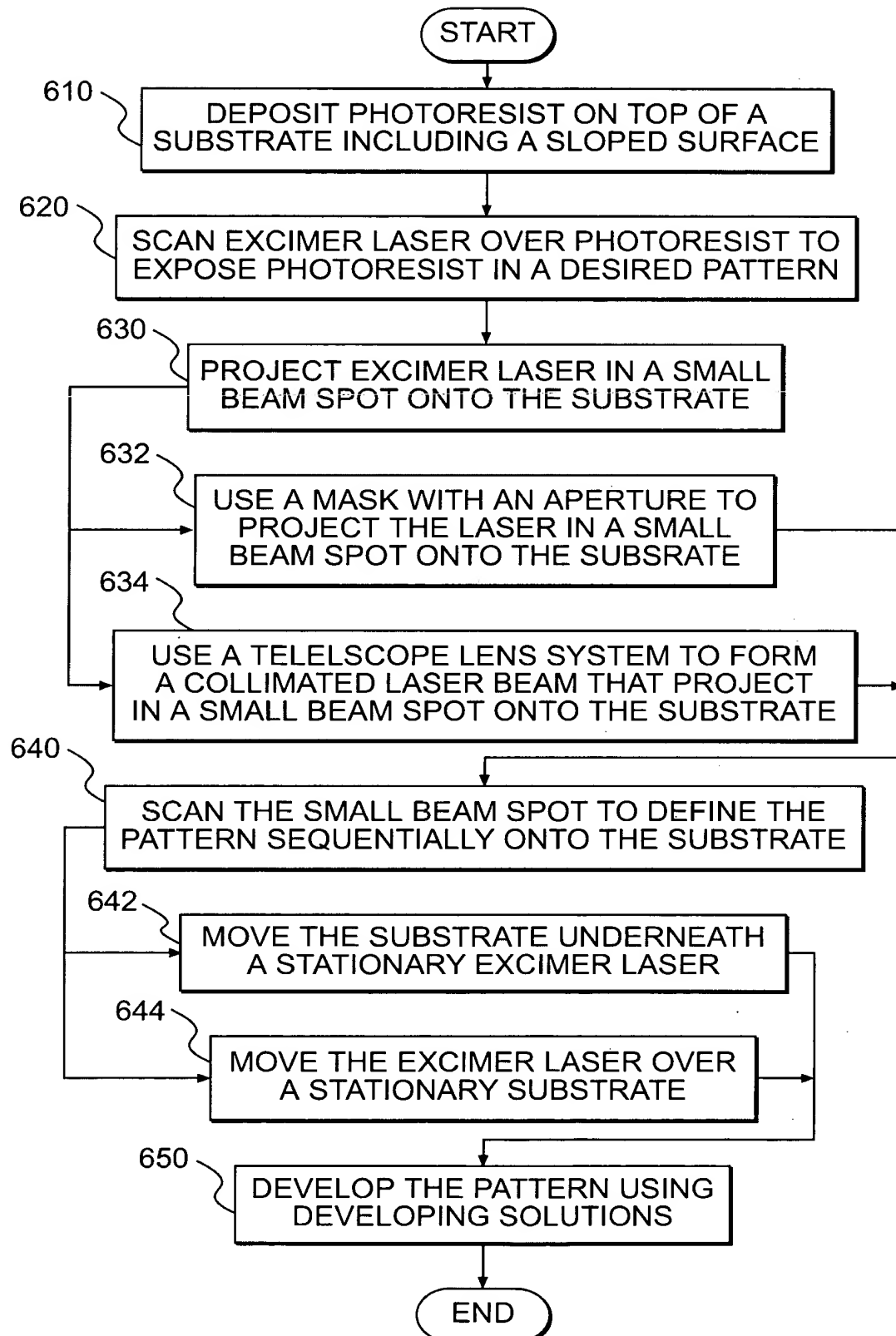


FIG. 6